Certificate of Analysis



Revision No.: 000

Revision Date: 12/12/2023

Certified Reference Material

Product ID: IARM-COR30016-22-G

Product Description: Cobalt Alloy, Stellite 6B/ R30016

Description and Intended Use: This Certified Reference Material is covered under the scope of accreditation to ISO 17034 by LGC Standards - Manchester, NH. As an ISO 17034 certified reference material, appropriate use of this material will fulfill the certified reference material and traceability requirements for use in ISO 17025 accredited laboratories. This CRM may come in the form of a solid disk, or chips. The intended use of this CRM may include, but is not limited to, the calibration of instruments and the validation of analytical methods.

Certified values listed in wt.% with associated uncertainties												
AI	0.054	± 0.003	В	0.0021	± 0.0009	С	1.10	± 0.02	Co	57.6	±0.3	
Cr	30.9	± 0.3	Cu	0.015	± 0.002	Fe	0.84	± 0.03	Mn	1.50	± 0.02	
Мо	0.97	± 0.02	Ν	0.026	± 0.001	Nb	0.037	± 0.004	Ni	2.86	±0.03	
0	0.0012	± 0.0003	Р	0.0045	± 0.0009	Si	0.65	± 0.02	Ti	0.0076	± 0.0006	
۷	0.011	± 0.001	W	4.01	± 0.04							

Indicative Values listed in ppm

S 4 Sn 5 Ta 151 Zr 6

Homogeneity and Uncertainty: "Uncertainty" values, as reported adjacent to certified concentration values, are based on a 95% Confidence Interval. These estimated uncertainties include the combined effects of method imprecision, material inhomogeneity, and any bias between methods. Homogeneity data from experimental XRF results are reflected in both the overall statistics and certified data. Homogeneity samples are selected by a systematic sampling procedure. The number of samples may be determined by equation 1, where N_{prod} is the number of units produced and N_{min} is the number of samples used for homogeneity testing. These samples are arranged in a simple randomized design such that each sample is analyzed multiple times by XRF. Homogeneity may also be determined within sample using an applied version of ASTM E826. A single factor ANOVA is used to calculated uncertainty due to inhomogeneity (U_{hom}). Uncertainty of the material is calculated by equation 2, where H=U_{hom}, S= Standard deviation, t= t-value at 95% CI, and n= number of observations.

$$1.N_{MIN} = \max(10, \sqrt[3]{N_{PROD}})$$

2.
$$U_{CRM} = \frac{\sqrt{H^2 + S^2}}{\sqrt{n}} * t$$

Certification Laboratories: Much of the analytical work performed to assess this material has been carried out by laboratories with proven competence, as indicated by their accreditation to ISO 17025. It is an implicit requirement for this accreditation that analytical work should be performed with due traceability, via an unbroken chain of comparisons, each with stated uncertainty, to primary standards such as the mole, or to nationally- or internationally-recognised reference materials. Of the individual results herein, some have traceability (to the mole) via primary analytical methods. Some are traceable to substances of known stoichiometry. Most have traceability via commercial solutions. Furthermore, some results have additional traceability to NIST standards, as part of the analytical calibration or process control.

 Anderson Laboratories, Inc., Gree Applied Technical Services, Marie Dirats Laboratories, Westfield, MA EAG Laboratories, Liverpool, NY Elemental Analysis Inc., Lexingtor 	etta, GA • •	IMR Test Labs, Lansing, NY Instytut Metalurgii Zelaza, Gliwice, Poland Laboratory Testing, Inc., Hatfield, PA LGC Standards, Manchester, NH NSL Analytical Services, Cleveland, OH	• •	SGS MSi, Melrose Park, IL Sheffield Assay Office, Sheffield, England TEC Eurolab, Campogalliano, Italy
---	--------------------	--	--------	--

Instructions for Use: The test surface is on the opposite side of the labeled surface, which includes the material identification. The entire thickness of the unit is certified. However, the user is cautioned not to measure disks less than 2 mm thick when using X-ray fluorescence spectrometry. Each packaged disk has been prepared by finishing the test surface using a lathe. The user must determine the correct surface preparation procedure for each analytical technique. The user is cautioned to use care when either resurfacing the disk or performing additional polishing, as these processes may contaminate the surface. The minimum sample size for chips should be individually evaluated based on the analytical technique used; this would typically be greater than 0.1 grams. The material should be stored in a cool, dry location when not in use.

Chips are not recommended for gas analysis.

Period of Validity: The certification of this material is valid indefinitely, within the uncertainty specified, provided the material is handled and stored in accordance with the instructions stated on this certificate. The certification is nullified if the material is damaged, contaminated, otherwise modified, or used in a manner for which it was not intended.

Chuck Goudreau, Certifying Officer

December 12, 2023 Certification Date



ISO 17034 Accredited: Reference Materials Producer, Certificate # 2848.02 ISO/IEC 17025 Accredited: Chemical Testing, Certificate # 2848.01

Conditions of Sale and Supply: All CRMs & RMs sold are subject to applicable LGC Standard Terms and Conditions of Sale.



The following data represents all pertinent information reported as it applies to the chemical characterization of this material.

	AI	В	С	Co	Cr	Cu	Fe	Mn	Мо	N	Nb	Ni	0
1	0.0426	0.0010	1.027	57.27	29.79	0.0100	0.7430	1.413	0.9250	0.0229	0.0254	2.800	0.0007
2	0.0480	0.0015	1.077	57.30	30.46	0.0109	0.7560	1.475	0.9266	0.0240	0.0308	2.803	0.0011
3	0.0499	0.0017	1.080	57.32	30.53	0.0127	0.7910	1.486	0.9470	0.0252	0.0310	2.814	0.0012
4	0.0510	0.0018	1.100	57.63	30.53	0.0129	0.7940	1.490	0.9478	0.0254	0.0325	2.816	0.0012
5	0.0514	0.0021	1.104	57.79	30.58	0.0136	0.8050	1.500	0.9500	0.0257	0.0356	2.840	0.0012
6	0.0521	0.0023	1.107	57.93	30.75	0.0140	0.8300	1.504	0.9520	0.0260	0.0370	2.846	0.0015
7	0.0522	0.0042	1.120	57.94	30.77	0.0151	0.8452	1.504	0.9522	0.0260	0.0375	2.853	0.0018
8	0.0556	<0.005	1.123	57.97	30.79	0.0153	0.8564	1.506	0.9570	0.0264	0.0380	2.855	<0.0005
9	0.0564		1.125		30.83	0.0154	0.8574	1.510	0.9700	0.0270	0.0391	2.856	
10	0.0580		1.137		30.88	0.0169	0.8650	1.511	0.9770	0.0288	0.0405	2.876	
11	0.0580		1.142		31.12	0.0171	0.8694	1.522	0.9800	0.0294	0.0416	2.884	
12	0.0600				31.34	0.0216	0.8800	1.524	0.9830		0.0460	2.887	
13	0.0633				31.38		0.8850	1.525	0.9933		0.0465	2.890	
14					31.40		0.9000	1.543	1.0300			2.925	
15					31.62		0.9390	1.558	1.0480			3.030	
Mean	0.0537	0.0021	1.104	57.64	30.85	0.0146	0.8411	1.505	0.9693	0.0261	0.0370	2.865	0.0012
STDV	0.0055	0.0010	0.033	0.31	0.47	0.0031	0.0544	0.033	0.0345	0.0019	0.0061	0.058	0.0003
Certified	0.054	0.0021	1.10	57.6	30.9	0.015	0.84	1.50	0.97	0.026	0.037	2.86	0.0012
UCRM	0.003	0.0009	0.02	0.3	0.3	0.002	0.03	0.02	0.02	0.001	0.004	0.03	0.0003
Methods	I,IM,X,O	I,IM	С	I,X,O	I,X,O	I,IM,X,O	I,X,O	I,X,O	I,X,O	F	I,IM,X	I,X,O	F

	Р	S	Si	Sn	Та	Ti	V	W	Zr
1	0.0027	0.0002	0.5900	0.0002	0.0051	0.0058	0.0070	3.900	0.0001
2	0.0036	0.0003	0.6124	0.0002	0.0070	0.0064	0.0080	3.946	0.0002
3	0.0040	0.0004	0.6303	0.0011	0.0084	0.0070	0.0085	3.974	0.0008
4	0.0045	0.0005	0.6320	<.0002	0.0099	0.0070	0.0097	3.975	0.0012
5	0.0049	<.0005	0.6330	<.0010	0.0102	0.0070	0.0105	3.979	<.0005
6	0.0050	<0.0001	0.6345	<0.0001	0.0254	0.0075	0.0118	3.988	<0.0001
7	0.0050	<0.0001	0.6372	<0.0010	0.0270	0.0078	0.0119	4.003	<0.0010
8	0.0063	< 0.0003	0.6430	<0.005	0.0278	0.0080	0.0119	4.022	<0.005
9	<0.005	< 0.001	0.6750		<0.005	0.0080	0.0120	4.037	<0.005
10	< 0.005	<0.0010	0.6770		<0.01	0.0083	0.0126	4.044	
11	<0.0050	<0.0010	0.6917			0.0088	0.0127	4.060	
12			0.7210			0.0090	0.0142	4.089	
13			0.7210			<0.005	<0.01	4.119	
14									
15									
Mean	0.0045	0.0004	0.6537	0.0005	0.0151	0.0076	0.0109	4.010	0.0006
STDV	0.0011	0.0001	0.0403	0.0005	0.0098	0.0010	0.0022	0.060	0.0005
Certified	0.0045	(0.0004)	0.65	(0.0005)	(0.0151)	0.0076	0.011	4.01	(0.0006)
UCRM	0.0009		0.02			0.0006	0.001	0.04	
Methods	I,IM,X	С	I,X,O	IM	I,IM	I,IM,X,O	I,X,IM	I,X,O	I,IM

Legend: W = Classical, C = Combustion, F = Fusion, A = AA or GFAA, I = ICP or DCP, IM=ICP-MS, D = DC Arc, O = AES, X = XRF, G = GDAES or GDMS, H = Hollow Cathode AES

